

**Your manuscript RINP_2017_1938_R1 has been accepted**

From: Cong-Feng Qiao (Results in Physics)

To: Prof.Hariyadi

Reply To: qiaocf@ucas.ac.cn

Ref: RINP_2017_1938_R1

Title: Deposition of Cu-doped PbS thin films with low resistivity using DC sputtering

Journal: Results in Physics

Dear Professor soetedjo,

I am pleased to inform you that your paper has been accepted for publication. My own comments as well as any reviewer comments are appended to the end of this letter. Now that your manuscript has been accepted for publication it will proceed to copy-editing and production.

Thank you for submitting your work to Results in Physics. We hope you consider us again for future submissions.

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Kind regards,

Cong-Feng Qiao
Editor in Chief
Results in Physics

Comments from the editors and reviewers:**- Reviewer 1**

Results in Physics

Manuscript Number: RINP_2017_1938_Revision 1

Title: Deposition of Cu-doped PbS thin films with low resistivity using DC sputtering

Comments to the authors:

I have looked at the corrections and comments. In my opinion the Authors have addressed all concerns & the manuscript is suitable for publication.

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